The New Mexico Chapter of The American Vacuum Society Presents

2023 NMAVS Spring Symposium

Talks • Posters • Lunch • Awards • Vendor Show • Short Courses

Tuesday, May 23th, 2023

at the

Sheraton Airport Hotel in Albuquerque

We are accepting abstracts for talks (15 min slot) and posters (with 2 min intro) related to science at low pressures and/or controlled atmospheres including films and coatings, microelectronics, nanostructures, surfaces and interfaces, plasmas, vacuum, and manufacturing processes

Submit Abstracts by April 24th, 2023:

www.nmavs.org

For abstract submission and registration

REGISTRATION: FREE

LUNCH IS PROVIDED

PRIZES AWARDED FOR BEST PRESENTATION: POST-DOC; GRADUATE STUDENT; UNDERGRADUATE; PROFESSIONAL TECHNICIAN

PRIZES WILL ALSO BE PRESENTED FOR BEST POSTER

Best student talk will also receive up to $2000 travel reimbursement for this year's AVS International Symposium in Portland Oregon

Winners announced at the end of the symposium

Sean Smith, seansmith@ferrodevices.com – Symposium Organizer
David Adams, dadams205@comcast.net – Short Course Organizer
Tony Ohlhausen, TonyOhlhausen.nmavs@gmail.com - Vendor Show Organizer

The annual New Mexico AVS Technical Symposium will feature **SCIENTISTS AND ENGINEERS** at all levels of their career with special emphasis for **STUDENTS, TECHNOLOGISTS, AND EARLY CAREER RESEARCHERS**. This interdisciplinary, one-day forum allows for emerging scientists and engineers to present their research and collaborate with new colleagues. For students especially, the friendly exchange is valuable practice for future conferences and job presentations.

The AVS – Science & Technology Society is a non-profit professional society and a member of the American Institute of Physics (AIP). The New Mexico Chapter, includes New Mexico, Arizona, Oklahoma and that part of Texas in the Mountain Time Zone. The AVS is the foremost professional organization for practitioners in the diverse fields that depend on science at low pressures and/or controlled atmospheres including films and coatings, microelectronics, nanostructures, surfaces and interfaces, plasmas, vacuum, and manufacturing processes.